Kuan Y Cheong

List of Publications by Year in Descending Order

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The third column is the impact factor (IF) of the journal, and the fourth column is the number of citations of the article.

207
papers

3,620
citations

4,189
ext. papers

27
h-index

50
g-index

5.79
ext. citations

3
avg, IF

L-index

#	Paper	IF	Citations
207	Synergetic effects of monoethanolamine (MEA) and post-deposition calcination on biosynthesized CeO2 nanostructures spin-coated on silicon substrate. <i>Materials Chemistry and Physics</i> , 2022 , 278, 1256.	5 6 ·4	O
206	A review of laser ablation and dicing of Si wafers. <i>Precision Engineering</i> , 2022 , 73, 377-408	2.9	2
205	Natural biomaterial honey-based resistive switching device for artificial synapse in neuromorphic systems. <i>Applied Physics Letters</i> , 2022 , 120, 083301	3.4	O
204	Buoyant titanium dioxide (TiO2) as high performance photocatalyst and peroxide activator: A critical review on fabrication, mechanism and application. <i>Journal of Environmental Chemical Engineering</i> , 2022 , 10, 107549	6.8	1
203	Performance of Organic Polymer Electrolyte Based on Extracted Aloe Vera Polysaccharide Compared with Mannose, Agarose and Carboxymethyl-Cellulose (CMC) for DSCs Application. <i>Springer Proceedings in Complexity</i> , 2021 , 431-439	0.3	
202	Study of synaptic properties of honey thin film for neuromorphic systems. <i>Materials Letters</i> , 2021 , 1311	69 3	1
201	Nonvolatile resistive switching memory based on monosaccharide fructose film. <i>Applied Physics Letters</i> , 2021 , 119, 163302	3.4	1
200	Titanium Dioxide/Polyvinyl Alcohol/Cork Nanocomposite: A Floating Photocatalyst for the Degradation of Methylene Blue under Irradiation of a Visible Light Source. <i>ACS Omega</i> , 2021 , 6, 14493-	14 5 03	7
199	Resistive Switching Properties of ZrO2 Film by Plasma-Enhanced Atomic Layer Deposition for Non-volatile Memory Applications. <i>Journal of Electronic Materials</i> , 2021 , 50, 5396	1.9	O
198	Resistive switching behaviour in a polymannose film for multistate non-volatile memory application. <i>Journal of Materials Chemistry C</i> , 2021 , 9, 1437-1450	7.1	5
197	Femtosecond laser dicing of ultrathin Si wafers with Cu backside layer - A fracture strength and microstructural study. <i>Journal of Manufacturing Processes</i> , 2021 , 62, 859-872	5	1
196	The adhesion of epoxy treated by microwave oxygen plasma. <i>Applied Surface Science</i> , 2021 , 563, 15022	46.7	1
195	Review on resistive switching mechanisms of bio-organic thin film for non-volatile memory application. <i>Nanotechnology Reviews</i> , 2021 , 10, 680-709	6.3	11
194	High-k LaxCeyOz for Passivation of Si Substrate. <i>Journal of Physics: Conference Series</i> , 2020 , 1535, 01203	30 .3	
193	Mechanism study of SiO2 layer formation and separation at the Si die sidewall during nanosecond laser dicing of ultrathin Si wafers with Cu backside layer. <i>Applied Physics A: Materials Science and Processing</i> , 2020 , 126, 1	2.6	2
192	Investigation of honey thin film as a resistive switching material for nonvolatile memories. <i>Materials Letters</i> , 2020 , 271, 127796	3.3	7
191	Development and mechanical characterization of bilayer tubular scaffolds for vascular tissue engineering applications. <i>Journal of Materials Science</i> , 2020 , 55, 2516-2529	4.3	2

(2016-2020)

190	Investigation of honey as the electrolyte gate dielectrics of field effect transistors. <i>Microsystem Technologies</i> , 2020 , 26, 1717-1720	1.7	1	
189	Artificial Synaptic Behavior of Aloe Polysaccharides-Based Device with Au as Top Electrode. <i>MRS Advances</i> , 2020 , 5, 693-698	0.7	1	
188	Effects of Post-Deposition Annealing Time in Forming Gas Ambient on Y2O3 Films Deposited on Silicon Substrate. <i>Journal of Physics: Conference Series</i> , 2020 , 1535, 012031	0.3		
187	Effect of Template Deposition Method on Formation of AuNPs in Memory Devices Application. <i>Solid State Phenomena</i> , 2019 , 290, 67-74	0.4		
186	Switching Dynamics and Conductance Quantization of \$Aloe\$ Polysaccharides-Based Device. <i>IEEE Transactions on Electron Devices</i> , 2019 , 66, 3110-3117	2.9	10	
185	Fracture strength and microstructural study of ultrathin Si die with Cu backside layer diced with picosecond laser. <i>Materials Science & Engineering A: Structural Materials: Properties, Microstructure and Processing</i> , 2019 , 759, 785-796	5.3	2	
184	Post deposition annealing effect on properties of Y2O3/Al2O3 stacking gate dielectric on 4H-SiC. <i>Materials Letters</i> , 2019 , 245, 174-177	3.3	8	
183	An improved three-point bending test method for the investigation of nanosecond laser dicing of ultrathin Si dies with Cu stabilization layer. <i>Materials Characterization</i> , 2018 , 136, 29-40	3.9	6	
182	Effects of drying temperature on tomato-based thin film as self-powered UV photodetector. <i>Applied Surface Science</i> , 2018 , 445, 186-196	6.7	7	
181	Effects of Oxalic Acid on UV-C Sensing Property of Tomato Thin-Film Based Photodetector. <i>Journal of Physics: Conference Series</i> , 2018 , 1082, 012054	0.3		
180	Scanning electron microscopy of soxhlet extracted aloe vera gel for electrolyte application. <i>Journal of Physics: Conference Series</i> , 2018 , 1123, 012070	0.3	1	
179	Nonvolatile Memory Device Based on Bipolar and Unipolar Resistive Switching in Bio-Organic Aloe Polysaccharides Thin Film. <i>Advanced Materials Technologies</i> , 2018 , 3, 1800007	6.8	10	
178	Stress and thermal characterization of 4H-SiC microelectromechanical structures. <i>Materials Letters</i> , 2017 , 191, 196-199	3.3	2	
177	Filamentary Conduction in Aloe Vera Film for Memory Application. <i>Procedia Engineering</i> , 2017 , 184, 65	5-662	15	
176	Aloe vera in active and passive regions of electronic devices towards a sustainable development 2017 ,		3	
175	Effects of Various Heating Rate and Sintering Temperatures on the Microstructural and Die-Shear Strength of Sintered Ag-Cu Nanopaste. <i>Procedia Engineering</i> , 2017 , 184, 611-615		O	
174	Memory properties of Au nanoparticles prepared by tuning HAuCl4 concentration using low-temperature hydrothermal reaction. <i>Thin Solid Films</i> , 2016 , 615, 84-90	2.2	3	
173	Annealing temperature-dependent crystallinity and photocurrent response of anodic nanoporous iron oxide film. <i>Journal of Materials Research</i> , 2016 , 31, 1681-1690	2.5	5	

172	Effects of rapid thermal annealing on structural, chemical, and electrical characteristics of atomic-layer deposited lanthanum doped zirconium dioxide thin film on 4H-SiC substrate. <i>Applied Surface Science</i> , 2016 , 365, 296-305	6.7	8
171	Effects of Electrode Materials on Charge Conduction Mechanisms of Memory Device Based on Natural Aloe Vera. <i>MRS Advances</i> , 2016 , 1, 2513-2518	0.7	11
170	Embedded Nanoparticles in Schottky and Ohmic Contacts: A Review. <i>Critical Reviews in Solid State and Materials Sciences</i> , 2015 , 40, 197-222	10.1	27
169	Au nanoparticles embedded at the interface of Al/4H-SiC Schottky contacts for current density enhancement. <i>Applied Physics A: Materials Science and Processing</i> , 2015 , 118, 315-325	2.6	11
168	Effects of annealing time on the electrical properties of the Y2O3 gate on silicon. <i>Journal of Experimental Nanoscience</i> , 2015 , 10, 19-28	1.9	17
167	Ultrathin Wafer Pre-Assembly and Assembly Process Technologies: A Review. <i>Critical Reviews in Solid State and Materials Sciences</i> , 2015 , 40, 251-290	10.1	25
166	Effects of drying temperature and ethanol concentration on bipolar switching characteristics of natural Aloe vera-based memory devices. <i>Physical Chemistry Chemical Physics</i> , 2015 , 17, 26833-53	3.6	78
165	Growth of gold nanoparticles using aluminum template via low-temperature hydrothermal method for memory applications. <i>Journal of Materials Science: Materials in Electronics</i> , 2015 , 26, 6484-6494	2.1	4
164	Green synthesis of iron oxide thin-films grown from recycled iron foils. <i>Materials Science in Semiconductor Processing</i> , 2015 , 29, 294-299	4.3	6
163	Thermal characteristic of sintered Aglu nanopaste for high-temperature die-attach application. <i>International Journal of Thermal Sciences</i> , 2015 , 87, 169-177	4.1	23
162	Investigation of Aloe Vera as active layer for development of organic based memory devices. <i>Materials Technology</i> , 2015 , 30, A29-A35	2.1	15
161	Effect of Nanosecond Laser Dicing on the Mechanical Strength and Fracture Mechanism of Ultrathin Si Dies With Cu Stabilization Layer. <i>IEEE Transactions on Components, Packaging and Manufacturing Technology</i> , 2015 , 5, 1885-1897	1.7	5
160	Schottky barrier height engineering of Al contacts on Si by embedded Au nanoparticles. <i>Microelectronic Engineering</i> , 2015 , 133, 110-119	2.5	5
159	Surface Modification of Semiconductor by Simultaneous Thermal Oxidation and Nitridation 2015, 2997	-3029	
158	Direct formation of AuNPs thin film using thermal evaporated zinc as sacrificial template in hydrothermal method. <i>Journal of Materials Science: Materials in Electronics</i> , 2014 , 25, 2227-2236	2.1	4
157	Physical and Electrical Characteristics of Silver-Copper Nanopaste as Alternative Die-Attach. <i>IEEE Transactions on Components, Packaging and Manufacturing Technology,</i> 2014 , 4, 8-15	1.7	18
156	Mechanical properties of sintered Aglu die-attach nanopaste for application on SiC device. <i>Materials & Design</i> , 2014 , 64, 166-176		22
155	Characterization of ultrathin Al2O3 gate oxide deposited by RF-magnetron sputtering on gallium nitride epilayer on sapphire substrate. <i>Materials Chemistry and Physics</i> , 2014 , 148, 592-604	4.4	9

(2013-2014)

154	Investigation of SiO2 film growth on 4H-SiC by direct thermal oxidation and postoxidation annealing techniques in HNO3 & H2O vapor at varied process durations. <i>Thin Solid Films</i> , 2014 , 570, 138	3- 1 249	3	
153	Physical and dispersive optical characteristics of ZrON/Si thin-film system. <i>Applied Physics A:</i> Materials Science and Processing, 2014 , 115, 1069-1072	2.6	18	
152	Oxygen vacancy formation and annihilation in lanthanum cerium oxide as a metal reactive oxide on 4H-silicon carbide. <i>Physical Chemistry Chemical Physics</i> , 2014 , 16, 7015-22	3.6	25	
151	Retardation mechanism of ultrathin Al2O3 interlayer on Y2O3 passivated gallium nitride surface. <i>ACS Applied Materials & District ACS ACS Applied Materials & District ACS ACS ACS ACS ACS ACS ACS ACS ACS ACS</i>	9.5	14	
150	Effects of post-deposition annealing time in oxygen ambient on Y2O3 film deposited on silicon substrate. <i>Materials Research Innovations</i> , 2014 , 18, S6-495-S6-498	1.9	12	
149	Characterization Methods for Ultrathin Wafer and Die Quality: A Review. <i>IEEE Transactions on Components, Packaging and Manufacturing Technology</i> , 2014 , 4, 2042-2057	1.7	19	
148	Effects of Post-Deposition Annealing Time on Metal-Organic Decomposed Lanthanum Cerium Oxide Film Spin-Coated on Si Substrate. <i>Advanced Materials Research</i> , 2014 , 1024, 364-367	0.5	1	
147	Effect of sintering environment on silver-copper die-attach nanopaste 2014,		1	
146	Post-Deposition Annealing in Nitrous Oxide Ambient of RF-Magnetron Sputtered Y2O3 Film on Silicon Substrate. <i>Advanced Materials Research</i> , 2014 , 1024, 360-363	0.5	2	
145	Influence of post-deposition annealing time on oxygen gas sensing behaviour of Al/La0I50Ce0I50O1I75/Si metal-oxide-semiconductor capacitor. <i>Materials Research Innovations</i> , 2014 , 18, S6-490-S6-494	1.9	2	
144	Deposition of Gold Nanoparticles on Linker-Free Silicon Substrate by Spin-Coating. <i>Advanced Materials Research</i> , 2014 , 1024, 124-127	0.5	2	
143	The Effect of Hydrothermal Reaction Time on Formation of AuNPs by Sacrificial Templated Growth Hydrothermal Approach. <i>Advanced Materials Research</i> , 2014 , 1024, 71-74	0.5		
142	Advances in Smart Materials and Applications. <i>Advances in Materials Science and Engineering</i> , 2014 , 2014, 1-1	1.5		
141	The effect of size and shape of gold nanoparticles on thin film properties. <i>Journal of Experimental Nanoscience</i> , 2014 , 9, 64-77	1.9	8	
140	Thermal and photo reversible gel\(\text{Sol}\) of azobenzene based liquid crystalline organogel. Journal of Photochemistry and Photobiology A: Chemistry, 2014 , 278, 19-24	4.7	9	
139	Effects of Post-deposition Annealing Time in Nitrogen Ambient on Y2O3 Films Deposited on Silicon 2014 , 649-655			
138	Surface Modification of Semiconductor by Simultaneous Thermal Oxidation and Nitridation 2014 , 1-28			
137	Gold nanoparticles deposited on linker-free silicon substrate and embedded in aluminum Schottky contact. <i>Journal of Colloid and Interface Science</i> , 2013 , 408, 220-8	9.3	16	

136	Recent development of gallium oxide thin film on GaN. <i>Materials Science in Semiconductor Processing</i> , 2013 , 16, 1217-1231	4.3	25
135	A novel silverlluminium high-temperature die attach nanopaste system: the effects of organic additives content on post-sintered attributes. <i>Journal of Materials Science: Materials in Electronics</i> , 2013 , 24, 2678-2688	2.1	7
134	Effect of Oxidation Time on Thermally Grown Oxide on GaN. <i>Journal of Materials Engineering and Performance</i> , 2013 , 22, 1341-1347	1.6	7
133	Effects of post-deposition annealing ambient on band alignment of RF magnetron-sputtered Y2O3 film on gallium nitride. <i>Nanoscale Research Letters</i> , 2013 , 8, 53	5	11
132	Investigation of thermally grown oxide on 4H-SiC by a combination of H2O and HNO3 vapor with varied HNO3 solution heating temperature. <i>Applied Surface Science</i> , 2013 , 285, 795-804	6.7	5
131	Microstructural and optical properties of ZrON/Si thin films. <i>Materials Letters</i> , 2013 , 105, 72-75	3.3	27
130	Effects of post-deposition annealing ambient on chemical, structural, and electrical properties of RF magnetron sputtered Y2O3 gate on gallium nitride. <i>Journal of Alloys and Compounds</i> , 2013 , 575, 382	2-392	22
129	Ultralow Voltage Operation of \${rm Al}/{rm La}_{x}{rm Ce}_{1-x}{rm O}_{z}/{rm 4Hhbox{-}SiC}\$ for Oxygen Sensing. <i>IEEE Electron Device Letters</i> , 2013 , 34, 1430-1432	4.4	2
128	Physical and electrical attributes of sintered Ag80Al20 high temperature die attach material with different organic additives content. <i>Journal of Materials Science: Materials in Electronics</i> , 2013 , 24, 720-7	733 ¹	10
127	Effects of post-deposition annealing temperature on metal-organic decomposed lanthanum cerium oxide film as metal reactive oxide layer on 4H-SiC. <i>Materials Chemistry and Physics</i> , 2013 , 140, 622-633	4.4	16
126	Effect of Zinc Nitrate Concentration on Formation of AuNPs by Sacrificial Templated Growth Hydrothermal Approach and its Properties in Organic Memory Device. <i>Advanced Materials Research</i> , 2013 , 858, 67-73	0.5	
125	Current conduction mechanisms of RF-Magnetron sputtered Y2O3 gate oxide on gallium nitride. <i>Current Applied Physics</i> , 2013 , 13, 1433-1439	2.6	13
124	Study of molar ratio on the characteristics of metal of alloys and Compounds, 2013 , 581, 793-800	5.7	16
123	Comparison of oxidized/nitrided Zr thin films on Si and SiC substrates. <i>Ceramics International</i> , 2013 , 39, S475-S479	5.1	7
122	Advances of Ag, Cu, and Aglīu alloy nanoparticles synthesized via chemical reduction route. <i>Journal of Nanoparticle Research</i> , 2013 , 15, 1	2.3	115
121	Reliability of sintered Ag80Al20 die attach nanopaste for high temperature applications on SiC power devices. <i>Microelectronics Reliability</i> , 2013 , 53, 473-480	1.2	15
120	Aloe vera gel as natural organic dielectric in electronic application. <i>Journal of Materials Science: Materials in Electronics</i> , 2013 , 24, 2646-2652	2.1	23
119	Fabrication of well-crystallized mesoporous ZrO2 thin films via Pluronic P123 templated solgel route. <i>Ceramics International</i> , 2013 , 39, S437-S440	5.1	9

118	Design of hierarchically mesofinacroporous tetragonal ZrO2 thin films with tunable thickness by spin-coating via solgel template route. <i>Microporous and Mesoporous Materials</i> , 2013 , 167, 198-206	5.3	9
117	Surface passivation of gallium nitride by ultrathin RF-magnetron sputtered Al2O3 gate. <i>ACS Applied Materials & Amp; Interfaces</i> , 2013 , 5, 6860-3	9.5	16
116	Structural and Chemical Studies of Metal®rganic Decomposed LaxCeyOz Thin Film as a Catalytic Oxide on 4H-SiC as a Function of Postdeposition Annealing Time. <i>Journal of Physical Chemistry C</i> , 2013 , 117, 14014-14024	3.8	18
115	Effect of spent bleaching earth based bio organic fertilizer on growth, yield and quality of eggplants under field condition 2013 ,		2
114	Nanoindentation of Porous Die Attach Materials as a Means of Determining Mechanical Attributes. <i>Applied Mechanics and Materials</i> , 2013 , 393, 57-62	0.3	
113	Effect of Sintering Temperature on Silver-Copper Nanopaste as High Temperature Die Attach Material. <i>Advanced Materials Research</i> , 2013 , 795, 47-50	0.5	9
112	Effects of SiO2 Nanoparticles on Dielectric Characteristic of Aloe Vera Paste. <i>Advanced Materials Research</i> , 2013 , 858, 74-79	0.5	2
111	Effects of wet-oxidized 4H-SiC annealed in HNO3/H2O vapour. <i>Microelectronics International</i> , 2013 , 31, 42-53	0.8	2
110	Formation of Anodic Oxide Nanotubes in H2O2 - Fluoride Ethylene Glycol Electrolyte as Template for Electrodeposition of Fe2O3. <i>Advanced Materials Research</i> , 2013 , 832, 333-337	0.5	2
109	N-Type Organic Field-Effect Transistor Based on Fullerene with Natural Aloe Vera/SiO2Nanoparticles as Gate Dielectric. <i>ECS Journal of Solid State Science and Technology</i> , 2013 , 2, P440-P444	2	13
108	Electrical study of ZrO2/Si system formed at different oxidation/nitridation temperatures for extended duration in N2O ambient. <i>Journal of Materials Research</i> , 2013 , 28, 2985-2989	2.5	2
107	Current Conduction Mechanisms in RF-Magnetron Sputtered Y2O3 Gate on GaN Under Different Post-Deposition Annealing Ambient. <i>Science of Advanced Materials</i> , 2013 , 5, 1816-1827	2.3	6
106	Effects of oxidation and nitridation temperatures on electrical properties of sputtered Zr thin film based on Si in N2O ambient. <i>Electronic Materials Letters</i> , 2012 , 8, 47-51	2.9	7
105	Influence of post-deposition annealing in oxygen ambient on metalBrganic decomposed CeO2 film spin coated on 4H-SiC. <i>Journal of Materials Science: Materials in Electronics</i> , 2012 , 23, 257-266	2.1	20
104	Effects of applied voltage on the properties of anodic zirconia thin film on (100) silicon. <i>Thin Solid Films</i> , 2012 , 522, 117-124	2.2	4
103	Sintering of Ag80-Al20 nanoalloy for high temperature die attach applications on silicon carbide-based power devices: The effects of ramp rate and dwell time 2012 ,		1
102	Growth of SiC nanowires using oil palm empty fruit bunch fibres infiltrated with tetraethyl orthosilicate. <i>Physica E: Low-Dimensional Systems and Nanostructures</i> , 2012 , 44, 2041-2049	3	8
101	Formation of Zr-oxynitride thin films on 4H-SiC substrate. <i>Thin Solid Films</i> , 2012 , 520, 6822-6829	2.2	22

100	Elaboration and characterization of solgel derived ZrO2 thin films treated with hot water. <i>Applied Surface Science</i> , 2012 , 258, 5250-5258	6.7	47
99	Effects of post-deposition annealing ambient on Y2O3 gate deposited on silicon by RF magnetron sputtering. <i>Journal of Alloys and Compounds</i> , 2012 , 529, 73-83	5.7	35
98	Direct formation of gold nanoparticles on substrates using a novel ZnO sacrificial templated-growth hydrothermal approach and their properties in organic memory device. <i>Nanoscale Research Letters</i> , 2012 , 7, 563	5	8
97	Study on Gallium Nitride-Based Metal Dxide Demiconductor Capacitors With RF Magnetron Sputtered \$hbox{Y}_{2}hbox{O}_{3}\$ Gate. IEEE Transactions on Electron Devices, 2012, 59, 3009-3016	2.9	18
96	Properties of thermally oxidized and nitrided Zr-oxynitride thin film on 4HBiC in diluted N2O ambient. <i>Materials Chemistry and Physics</i> , 2012 , 136, 624-637	4.4	8
95	Effect of oxidation temperature on physical properties of thermally grown oxide on GaN in N2O ambient. <i>Materials Chemistry and Physics</i> , 2012 , 137, 381-388	4.4	5
94	Synthesis of SiC nanostructures through chemical vapor growth route. <i>Materialwissenschaft Und Werkstofftechnik</i> , 2012 , 43, 412-415	0.9	1
93	Growth of SiC nanowires and nanocones using mixture of oil palm fibres and rice husk ash. <i>Journal of Materials Science</i> , 2012 , 47, 5477-5487	4.3	17
92	Metal-oxide-semiconductor characteristics of lanthanum cerium oxide film on Si. <i>Applied Physics A: Materials Science and Processing</i> , 2012 , 107, 459-467	2.6	18
91	Sintering of SilverAluminum Nanopaste With Varying Aluminum Weight Percent for Use as a High-Temperature Die-Attach Material. <i>IEEE Transactions on Components, Packaging and Manufacturing Technology</i> , 2012 , 2, 1940-1948	1.7	21
90	Metal-Oxide-Semiconductor Characteristics of Zr-Oxynitride Thin Film on 4H-SiC Substrate. <i>Journal of the Electrochemical Society</i> , 2012 , 159, H293-H299	3.9	18
89	Effects of Post-Deposition Annealing Temperature on Band Alignment and Electrical Characteristics of Lanthanum Cerium Oxide on 4H-SiC. <i>Materials Research Society Symposia Proceedings</i> , 2012 , 1433, 7		5
88	Effect of Sintering Time on Silver-Aluminium Nanopaste for High Temperature Die Attach Applications. <i>Advanced Materials Research</i> , 2012 , 576, 199-202	0.5	2
87	Effect of sputtering time on physical and electrical properties of ZrOxthin film on Si. <i>Microelectronics International</i> , 2011 , 28, 7-11	0.8	
86	Die Attach Materials for High Temperature Applications: A Review. <i>IEEE Transactions on Components, Packaging and Manufacturing Technology</i> , 2011 , 1, 457-478	1.7	254
85	Thermal oxidation and nitridation of sputtered Zr thin film on Si via N2O gas. <i>Journal of Alloys and Compounds</i> , 2011 , 509, 8728-8737	5.7	33
84	Design and synthesis of mesoporous ZrO2 thin films using surfactant Pluronic P123 via sol-gel technique. <i>Journal of the Ceramic Society of Japan</i> , 2011 , 119, 517-521	1	6
83	Deposition and post-deposition annealing of thin Y2O3 film on n-type Si in argon ambient. Materials Chemistry and Physics, 2011, 130, 1007-1015	4.4	24

82	Effect of Postdeposition Annealing in Oxygen Ambient on Gallium-Nitride-Based MOS Capacitors With Cerium Oxide Gate. <i>IEEE Transactions on Electron Devices</i> , 2011 , 58, 122-131	2.9	27
81	Band alignment and enhanced breakdown field of simultaneously oxidized and nitrided Zr film on Si. <i>Nanoscale Research Letters</i> , 2011 , 6, 489	5	18
80	Effect of process parameters on size, shape, and distribution of Sb2O3 nanoparticles. <i>Journal of Materials Science</i> , 2011 , 46, 5129-5139	4.3	6
79	Oxidation of sputtered Zr thin film on Si substrate. <i>Journal of Materials Science: Materials in Electronics</i> , 2011 , 22, 143-150	2.1	25
78	Investigation of forming-gas annealed CeO2 thin film on GaN. <i>Journal of Materials Science:</i> Materials in Electronics, 2011 , 22, 583-591	2.1	24
77	Effects of post-deposition annealing temperature and ambient on RF magnetron sputtered Sm2O3 gate on n-type silicon substrate. <i>Journal of Materials Science: Materials in Electronics</i> , 2011 , 22, 1816-182	26 ^{.1}	15
76	Controlled synthesis of Sb2O3 nanoparticles by chemical reducing method in ethylene glycol. Journal of Nanoparticle Research, 2011 , 13, 2807-2818	2.3	12
75	Physical and electrical characteristics of metal-organic decomposed CeO2 gate spin-coated on 4H-SiC. <i>Applied Physics A: Materials Science and Processing</i> , 2011 , 103, 1067-1075	2.6	23
74	Effect of postdeposition annealing on electrical properties of RF-magnetron sputtered CeOx gate on 4H-silicon carbide. <i>Physica Status Solidi (A) Applications and Materials Science</i> , 2011 , 208, 1925-1930	1.6	2
73	Chemical reduction methods for synthesizing Ag and Al nanoparticles and their respective nanoalloys. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2011 , 176, 187-203	3.1	47
72	Effects of post-oxidation annealing temperature on ZrO2 thin film deposited on 4H-SiC substrate. <i>Materials Science in Semiconductor Processing</i> , 2011 , 14, 13-17	4.3	22
71	Effect of post-deposition annealing temperature on CeO2 thin film deposited on silicon substrate via RF magnetron sputtering technique. <i>Materials Science in Semiconductor Processing</i> , 2011 , 14, 101-10	7 4.3	12
7°	A review on the synthesis of SiC from plant-based biomasses. <i>Materials Science and Engineering B: Solid-State Materials for Advanced Technology</i> , 2011 , 176, 951-964	3.1	65
69	Comparison of metal-organic decomposed (MOD) cerium oxide (CeO2) gate deposited on GaN and SiC substrates. <i>Journal of Crystal Growth</i> , 2011 , 326, 2-8	1.6	33
68	Effects of post-deposition annealing temperature and time on physical properties of metal-organic decomposed lanthanum cerium oxide thin film. <i>Thin Solid Films</i> , 2011 , 519, 5139-5145	2.2	20
67	Influence of post-deposition annealing on metal-organic decomposed lanthanum cerium oxide film 2011 ,		5
66	Electrical Characteristics of OxidizedNitrided Zr Thin Film on Si. <i>Journal of the Electrochemical Society</i> , 2011 , 158, H1270	3.9	21
65	FORTHCOMING GALLIUM NITRIDE BASED POWER DEVICES IN PROMPTING THE DEVELOPMENT OF HIGH POWER APPLICATIONS. <i>Modern Physics Letters B</i> , 2011 , 25, 77-88	1.6	6

64	Effects of N2O Postdeposition Annealing on Metal-Organic Decomposed CeO2 Gate Oxide Spin-Coated on GaN Substrate. <i>Journal of the Electrochemical Society</i> , 2011 , 158, H423	3.9	21
63	Electrical Properties of Pulsed Laser Deposited Y[sub 2]O[sub 3] Gate Oxide on 4HBiC. Electrochemical and Solid-State Letters, 2010 , 13, H396		25
62	Improved 4H-SiC MOS Interface Produced by Oxidized-SiN Gate Oxide. <i>Materials Science Forum</i> , 2010 , 645-648, 511-514	0.4	2
61	Ag/PEPC/NiPc/ZnO/Ag thin film capacitive and resistive humidity sensors. <i>Journal of Semiconductors</i> , 2010 , 31, 054002	2.3	15
60	Effects of Postdeposition Annealing in Argon Ambient on Metallorganic Decomposed CeO[sub 2] Gate Spin Coated on Silicon. <i>Journal of the Electrochemical Society</i> , 2010 , 157, H6	3.9	52
59	Effects of rapid thermal annealing on Al2O3/SiN reaction barrier layer/thermal-nitrided SiO2 stacking gate dielectrics on n-type 4H-SiC. <i>Applied Physics Letters</i> , 2010 , 96, 122108	3.4	6
58	MOS Characteristics of Metallorganic-Decomposed CeO[sub 2] Spin-Coated on GaN. <i>Electrochemical and Solid-State Letters</i> , 2010 , 13, H116		19
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	Letters, 2007, 10, H327 Electrical Properties of Atomic-Layer-Deposited La2O3/Thermal-Nitrided SiO2 Stacking Dielectric	0.4	
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18	Electrical Properties of Atomic-Layer-Deposited La2O3/Thermal-Nitrided SiO2 Stacking Dielectric on 4H-SiC(0001). <i>Materials Science Forum</i> , 2007 , 556-557, 643-646 Effects of thermal nitrided gate-oxide thickness on 4H silicon-carbide-based metal-oxide-semiconductor characteristics. <i>Applied Physics Letters</i> , 2007 , 90, 012120 Effects of rapid thermal annealing on nitrided gate oxide grown on 4H-SiC. <i>Microelectronic</i>	3.4	8
18 17 16	Electrical Properties of Atomic-Layer-Deposited La2O3/Thermal-Nitrided SiO2 Stacking Dielectric on 4H-SiC(0001). <i>Materials Science Forum</i> , 2007 , 556-557, 643-646 Effects of thermal nitrided gate-oxide thickness on 4H silicon-carbide-based metal-oxide-semiconductor characteristics. <i>Applied Physics Letters</i> , 2007 , 90, 012120 Effects of rapid thermal annealing on nitrided gate oxide grown on 4H-SiC. <i>Microelectronic Engineering</i> , 2006 , 83, 65-71 Current conduction mechanisms in post-nitridation rapid-thermal-annealed gate oxides on 4H	3.4	8 28 15
18 17 16	Electrical Properties of Atomic-Layer-Deposited La2O3/Thermal-Nitrided SiO2 Stacking Dielectric on 4H-SiC(0001). <i>Materials Science Forum</i> , 2007 , 556-557, 643-646 Effects of thermal nitrided gate-oxide thickness on 4H silicon-carbide-based metal-oxide-semiconductor characteristics. <i>Applied Physics Letters</i> , 2007 , 90, 012120 Effects of rapid thermal annealing on nitrided gate oxide grown on 4H-SiC. <i>Microelectronic Engineering</i> , 2006 , 83, 65-71 Current conduction mechanisms in post-nitridation rapid-thermal-annealed gate oxides on 4H silicon carbide. <i>Applied Physics Letters</i> , 2005 , 87, 212102 Investigation of ultralow leakage in MOS capacitors on 4H SiC. <i>IEEE Transactions on Electron Devices</i>	3.4 2.5 3.4	8 28 15
18 17 16 15	Electrical Properties of Atomic-Layer-Deposited La2O3/Thermal-Nitrided SiO2 Stacking Dielectric on 4H-SiC(0001). <i>Materials Science Forum</i> , 2007 , 556-557, 643-646 Effects of thermal nitrided gate-oxide thickness on 4H silicon-carbide-based metal-oxide-semiconductor characteristics. <i>Applied Physics Letters</i> , 2007 , 90, 012120 Effects of rapid thermal annealing on nitrided gate oxide grown on 4H-SiC. <i>Microelectronic Engineering</i> , 2006 , 83, 65-71 Current conduction mechanisms in post-nitridation rapid-thermal-annealed gate oxides on 4H silicon carbide. <i>Applied Physics Letters</i> , 2005 , 87, 212102 Investigation of ultralow leakage in MOS capacitors on 4H SiC. <i>IEEE Transactions on Electron Devices</i> , 2004 , 51, 1361-1365 Comparison of chargeEetention times in n- and p-type 4HBiC MOS capacitors as non-volatile	3·4 2.5 3·4 2.9	8 28 15 15

LIST OF PUBLICATIONS

1	10	Investigation of electron-hole generation in MOS capacitors on 4H SiC. <i>IEEE Transactions on Electron Devices</i> , 2003 , 50, 1433-1439	2.9	10	
٥	9	Channel-carrier mobility parameters for 4H SiC MOSFETs. <i>Microelectronics Reliability</i> , 2003 , 43, 405-411	1.2	19	
8	8	Polymorphisms in lymphotoxin alpha and CD14 genes influence TNFalpha production induced by Gram-positive and Gram-negative bacteria. <i>Genes and Immunity</i> , 2003 , 4, 283-8	4.4	42	
7	7	Mechanisms responsible for improvement of 4HBiC/SiO2 interface properties by nitridation. <i>Applied Physics Letters</i> , 2003 , 82, 568-570	3.4	170	
(6	Electrical and physical characterization of gate oxides on 4H-SiC grown in diluted N2O. <i>Journal of Applied Physics</i> , 2003 , 93, 5682-5686	2.5	69	
	5	Electrical and optical studies of ZnO:Ga thin films fabricated via the solgel technique. <i>Thin Solid Films</i> , 2002 , 410, 142-146	2.2	158	
4	4	Charge retention in metal®xide®emiconductor capacitors on SiC used as nonvolatile-memory elements. <i>Applied Physics Letters</i> , 2002 , 80, 3421-3423	3.4	13	
3	3	MOS capacitor on 4H-SiC as a nonvolatile memory element. <i>IEEE Electron Device Letters</i> , 2002 , 23, 404-4	.0 ₁6₄	18	
2	2	Can MHC class II genes mediate resistance to type 1 diabetes?. <i>Immunology and Cell Biology</i> , 2001 , 79, 602-6	5	12	
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